

1

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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/061,542	10/25/2001	Annette M. Crevasse	CREVASSE 52-104-78-8	2716	
27964 7:	590 09/15/2003				
HITT GAINES P.C.			EXAMINER		
P.O. BOX 832570			TD ANI DINILI V		
RICHARDSON	N, TX 75083		IRAN, D	TRAN, BINH X	
			ART UNIT	PAPER NUMBER	
			1765	Q.	
			DATE MAILED: 09/15/2003		
				<i>i</i>	

Please-find-below and/or attached an Office communication concerning this application or proceeding.

•		Application No.	Applicant(s)	
		10/061,542	CREVASSE ET AL.	
	Office Action Summary	Examiner	Art Unit	
		Binh X Tran	1765	
Period fo	The MAILING DATE of this communication app			
THE I - Externanter - If the - If NO - Failu - Any r	ORTENED STATUTORY PERIOD FOR REPL' MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a repl period for reply is specified above, the maximum statutory period or re to reply within the set or extended period for reply will, by statute eply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may within the statutory minimum of vill apply and will expire SIX (6), cause the application to becon	by a reply be timely filed  If thirty (30) days will be considered timely.  MONTHS from the mailing date of this communication.  BE ABANDONED (35 U.S.C. § 133).	
1)⊠	Responsive to communication(s) filed on 04 /	<u> August 2003</u> .		
2a)⊠	This action is FINAL. 2b) Th	is action is non-final.		
3)□ Dispositi	Since this application is in condition for allowationsed in accordance with the practice under on of Claims			
4)🛛	·Claim(s) <sup>.</sup> · <u>8-21</u> -is/are-pending-in-the-application	ì.		
	4a) Of the above claim(s) <u>10 and 18</u> is/are with	drawn from considerat	ion.	
5)□	Claim(s) is/are allowed.			
6)⊠	Claim(s) <u>8,11-16 and 19-21</u> is/are rejected.			
7)⊠ Claim(s) <u>9 and 17</u> is/are objected to.				
8)[X]	Claim(s) 6-2 1 are subject to restriction and/o	r election requirement.		
Applicati	on Papers			
9) 🗌 -	The specification is objected to by the Examine	r.		
10) 🔲 🗆	Γhe drawing(s) filed on is/are: a)☐ accep	oted or b) objected to	by the Examiner.	
	Applicant may not request that any objection to the	e drawing(s) be held in a	peyance. See 37 CFR 1.85(a).	
11) 🔲 🗆	The proposed drawing correction filed on	_is: a)□ approved b)[	disapproved by the Examiner.	
	If approved, corrected drawings are required in rep	bly to this Office action.		
12) 🗌 🗆	The oath or declaration is objected to by the Ex	aminer.		
Priority u	nder 35 U.S.C. §§ 119 and 120			
13)	Acknowledgment is made of a claim for foreigr	priority under 35 U.S.	C. § 119(a)-(d) or (f).	
a)[	☐ All b) ☐ Some * c) ☐ None of:			
	1. Certified copies of the priority documents	s have been received.		
	<ol><li>Certified copies of the priority documents</li></ol>	s have been received i	n Application No	
	<ol> <li>Copies of the certified copies of the prior application from the International Buree the attached detailed Office action for a list</li> </ol>	reau (PCT Rule 17.2(a	)).	
14)∐ A	cknowledgment is made of a claim for domesti	c priority under 35 U.S	C. § 119(e) (to a provisional application).	
	☐ The translation of the foreign language procknowledgment is made of a claim for domesti			
Attachment	(s)			
2) Notice	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice	ew Summary (PTO-413) Paper No(s) of Informal Patent Application (PTO-152)	
S. Patent and Tra TOL-326 (Re		tion Summary	Part of Paper No. 9	

#### **DETAILED ACTION**

## Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 3. Claims 8, 11-13, 15-16, 19-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lu et al. (US 6,524,959) in view of Birang et al. (US 6,537,133).

Lu discloses a method of determining a polishing endpoint comprising:

emitting the first signal (22) from an emitter (20) located at first location and causing the first signal to pass through a polished film (18, 16, 14, 12) located on a semiconductor wafer (10) and thereby provide a second signal (24b-24e) having signal intensity;

Art Unit: 1765

receiving the second signal (24b-24e) emanating from the film with a receiver (26) at the second location (i.e., located at another location) (Fig 1);

determining a polishing endpoint for the film as a function of change of intensity of the second signal (Fig 2-3, col. 8 lines 20-45).

Lu does not explicitly disclose the endpoint was based on a function of a change in intensity between the first and the second signals. However, Lu clearly discloses that the endpoint was determined by the change in intensity of the second signal. Since the intensity of the-first signal-(22)-from-the-radiation-beam-source-(20)-is-constant, any person in the art would understand that the change in intensity of the second signal with the constant in intensity of the first signal is equivalent with the change in intensity between the first and the second signals.

Lu fails to disclose that the intensity of second signal is less than the intensity of the first signal. In the polishing endpoint process using two signals, Birang discloses the second signal has a signal-to-noise ratio due to vibration from of the platen and wafer (col. 9 lines 13-35). Since the second signal has a noise and there is no amplifier for the second signal, the intensity of the second signal by itself must be less than the intensity of the first signal. It would have been obvious to one having ordinary skill in the art, at the time of invention, that the intensity of the second signal is less than the intensity of the first signal due to unavoidable signal-to-noise problem.

Lu also fails to explicitly disclose the exact location of the emitter (20) and the receiver (26). However, Lu clearly discloses the emitter (20) and the receiver (26) located at different location (Fig 1). Birang discloses the emitter (44) and receiver (48)

Art Unit: 1765

at different location either adjacent to one of the carrier head (12) or polishing platen (16). It would have been obvious to one having ordinary skill in the art, at the time of invention, to locate the emitter and the receiver adjacent to one of the carrier head and the polishing platen because it is the closest and most accurate place to measure the signal intensity.

Respect to claim 11, Lu discloses the first signal comprised of acoustic waves (col. 7 lines 7-9). Respect to claim 13, Lu discloses the acoustic wave having a plurality of wavelength (col. 7 lines 5-15). Since the frequency of the signal-directly-dependent the frequency, the examiner will interpret that Lu implicitly disclose the acoustic wave has plurality of frequency.

Respect to claim 12, Lu fails to disclose the first signal comprised of ultrasonic acoustic wavelength. However, Lu clearly discloses the use of acoustic wavelength. Birang disclose that ultrasonic wavelength has been used in the art to detect endpoint (col. 2 lines 25-27). It would have been obvious to one having ordinary skill in the art, at the time of invention, to modify Lu in view of Birang by using ultrasonic wavelength because equivalent and substitution of one for the other would produce an expected result.

Respect to claim 15, Lu further discloses the step of:
forming an integrated circuit layer (12-18) on a semiconductor wafer (10);
polishing the integrated circuit layer with a polishing apparatus;
striking the first signal on the integrated circuit to create a second signal (Fig 1).

Art Unit: 1765

All of the other limitation of claim 15 has been discussed above. Respect to claim 16, Lu discloses the second signal (24b-24e) is a resulting signal from the first signal striking the integrated circuit layer (Fig 1). The limitation of claims 19-20 has been discussed above.

4. Claims 14 and 21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lu and Birang in view of Tzeng (US 6,028,669).

Respect to claims 14 and 21, both Lu and Birang fail to disclose the polishing endpoint is based on a function of a change-of-a signal-wavelength-or signal-amplitude between the first and second signals. However, Lu clearly discloses that the polishing endpoint is based on a function of a change in signal intensity. In a polishing process, Tzeng discloses that the polishing endpoint is based on a function of change of the magnitude (i.e., intensity) with directly depend on signal amplitude (col. 6 lines 25-48). It would have been obvious to one having ordinary skill in the art, at the time of invention to modify Lu and Birang in view of Tzeng by determining the endpoint on the amplitude because it easy to calculate base on the signal intensity.

## Allowable Subject Matter

5. Claim 9, 17 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

## Response to Arguments

6. Applicant's arguments filed 8-4-2003 have been fully considered but they are not persuasive.

'Art Unit: 1765

First, there is a minor error in the in the status of the claim. In the response filed on 8-4-2003, the applicants indicates that "the applicants previously <u>canceled claims 1-7</u>, <u>10 and 18</u> and have not amended or added any claims" (page 1, line 1-2 of the second paragraphs). This appears to be a minor error. The applicants canceled claim 1-7 in the paper No. 4 filed on 1-23-2003. However, the applicants never cancel claims 10 and 18. Claims 10 and 18 were withdrawn (not cancel) from further consideration, as being drawn to a nonelected species.

The applicants argues that "Lu does not describe a signal transmitted from an emitter on one side of a semiconductor wafer, adjacent to either a carrier head or a polishing platen, with a second signal emanating from the opposite side of the wafer ... that was not adjacent the emitter". This argument is not commensurate with the scope of the claim. There is no limitation in the claim, which require that the second signal must emanate from the opposite side of the wafer [comparing with the first signal].

The applicants further argue that "Lu does not teach or suggest determining an endpoint by detecting signal on the opposite side of the wafer". Again, this argument is not commensurate with the scope of the claim. There is no limitation in the claim indicate that the endpoint is determined by detecting signal on the opposite side of the wafer. The examiner still maintain that the cited reference clearly disclose that the endpoint is base on the function of a change of the intensity between the first and the second signal.

The applicants further argues that Birang "does not teaches or suggest that an endpoint can be detected by generating a signal on one side of a wafer and detecting a second signal on the other side". Again, this argument is not commensurate with the scope of the claim. The applicants only claim that the endpoint is determined based on the function of change of intensity of two signals. The applicants never claim the relative position between the first signal and the second signal using the wafer as a base line.

#### **Conclusion**

7. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Binh X Tran whose telephone number is (703) 308-1867. The examiner can normally be reached on Monday-Thursday and every other Friday.

`Art Unit: 1765

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine G Norton can be reached on (703) 305-2667. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

Binh X. Tran

NADINE G. NORTON PRIMARY EXAMINER

Page 8